

226,048

HIGH-LOFT NONWOVEN MATERIAL

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fig. 1.

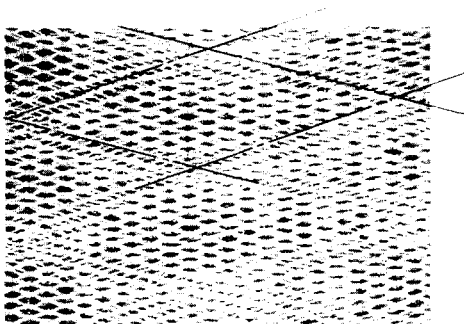


fig. 2.

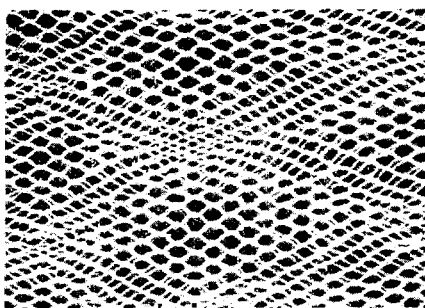


FIG. 1 is a top plan view of a high-loft nonwoven material showing our new design, the repeat unit being marked with intersecting lines, the design being shown over a dark background for purposes of illustration; and

FIG. 2 is a fragmentary top plan view thereof in a vertically stretched condition.

I claim:

The ornamental design for a high-loft nonwoven material, as shown and described.

References Cited

UNITED STATES PATENTS

D. 128,803	8/1941	Schiess	-----	D87—3
D. 217,211	4/1970	Rost	-----	D92—1
3,150,416	9/1964	Such	-----	19—161 P

LOIS S. LANIER, Primary Examiner